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	INFO	RMATIO	N DISC	CLOSURE	Application Number	Not Yet Assigned 10 1767764			
				PLICANT	Filing Date	January 29, 2004			
					First Named Inventor	Hineman et al.			
					Group Art Unit	Unknown~ 2826			
		(use as many si	heets as nec	essary)	Examiner Name	Unknown Kevin Quinto			
	Sheet	1	of	2	Attorney Docket Number	2269-5925US (03-0290.00/US)			

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Examiner Initials •	Cite No.	Number - Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevan Passages or Relevant	
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Examiner	Cite No. ¹	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T⁵	
Initials*		Country Code ³ - Number ⁴ - Kind Code ³ (if known)					
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Examiner Signature Levin Quinto Date Considered 6/26/05	5
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INEO		NI TAY	CLOCUDE	Application Number	Not Yet Assigned 10/767764		
			SCLOSURE	Filing Date	January 29, 2004		
STAT	EMENT E	BY A	PPLICANT	First Named Inventor	Hineman et al.		
•				Group Art Unit	Unknown 2826		
	(use as many sh	heets as r	necessary)	Examiner Name	Unknown Kevin Quinto		
Sheet	2	of	,	Attorney Docket Number	2269-5925115 (03-0290 00/115)		

		OTHER PRIOR ART NON PATENT LITERATURE DOCUMENTS						
Examiner Initials •	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²					
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Examiner Signature	Keun Quinto	Date Considered	6/26/05

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